Supplementary Information (SI)

## TiC<sub>2</sub>: A New Two Dimensional Sheet beyond MXenes

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### 1. Candidate structures of C<sub>2</sub> containing TiC<sub>2</sub>

By depositing  $C_2$  dimers on the surface of a monolayer triangular Ti lattice, we obtain three candidate structures of the 2D TiC<sub>2</sub> sheet.



**Fig. S1**  $C_2$  dimers inserted at different positions and with different orientations on the surface of a triangular Ti lattice. (a)  $C_2$  dimers bind to Ti atoms in EOC mode, and perpendicular to the nearest neighboring  $C_2$  dimers; (b)  $C_2$  dimers bind to Ti atoms in both SOC and EOC modes, and perpendicular to the near neighboring  $C_2$  dimers; (c)  $C_2$  dimers bind to Ti atoms in both SOC and EOC modes, but are all parallelly aligned.

#### 2. Stability relative to the 2D TiC<sub>2</sub> isomeric structures



**Fig. S2** Two energetically low-lying structural isomers of  $TiC_2$  containing  $C_2$  units. (a) and (b) are the initial structures; (c) and (d) are the corresponding optimized structures, respectively.

### 3. Stability relative to other Ti-C compounds

For comparison, we calculated the cohesive energy of TiC<sub>2</sub>, Ti<sub>3</sub>C<sub>2</sub> (MXene), bulk TiC, and some other Ti-C binary compounds. To gauge the relative stability of a compound with the composition of Ti<sub>x</sub>C<sub>1-x</sub>, using the method described by Zhang et al. <sup>1</sup>, we define its molar formation energy  $\delta F$  as

$$\delta F(Ti_{x}C_{1-x}) = E_{coh}(Ti_{x}C_{1-x}) - x\mu_{Ti} - (1-x)\mu_{C}$$
 \\* MERGEFORMAT (1)

where  $E_{coh}(x)$  is the cohesive energy of the system,  $\mu_{Ti}$  and  $\mu_C$  are the chemical potentials of the Ti and C atoms, respectively. The relative stability of different  $Ti_xC_{1-x}$  structures can be gauged by comparing their  $\delta F$ : higher  $\delta F$  means inferior stability. We here set  $\mu_C$  and  $\mu_{Ti}$  as the cohesive

energy of graphene and bulk *hcp* Ti. The results are summarized in Figure S3. A line connecting the cohesive energy of graphene and bulk Ti is used to estimate the stability of a Ti-C compound: a structure with cohesive energy below the line ( $\delta F <= 0$ ) is stable against discomposing into graphene and Ti; when  $\delta F > 0$ , the structure becomes metastable or even unstable. The recently predicted single-layer t-TiC<sup>1</sup> has a positive  $\delta F$  and hence is metastable. In contrast, the TiC<sub>2</sub> structure in our work has a negative  $\delta F$ , -0.40 eV, indicating a thermodynamically stability. The experimentally identified bulk TiC and 2D MXene (Ti<sub>3</sub>C<sub>2</sub> and Ti<sub>2</sub>C) also have negative  $\delta F$ . One should note that some Ti-C clusters, even though with positive  $\delta F$ , have been experimentally synthesized.<sup>2,3</sup> Therefore, the single-layer TiC<sub>2</sub> is thermodynamically favorable and may be formed when suitable synthetic conditions are provided.



Fig. S3 Cohesive energy for binary compounds with composition  $Ti_xC_{1-x}$ . The solid line links cohesive energies of graphene (x = 0) and bulk Ti (x=1). Formation energy  $\delta F$  is positive (negative) above (below) the solid line.

#### 4. Stability relative to other isostructural metal carbides

We replace the Ti atoms in  $TiC_2$  sheet with other 3d transition metal atoms forming a series of 2D MC<sub>2</sub> metal carbides. All structures are fully relaxed, and their cohesive energy are calculated as presented in Figure S4, which shows that  $TiC_2$  has the largest cohesive energy, indicating Ti atoms bind most strongly with C<sub>2</sub> dimers in such structure.



Fig. S4 Cohesive energy of 2D transition metal dicarbides  $MC_2$  (M=Sc-Co) in the TiC<sub>2</sub> structure.

# 5. Thermal stability of the TiC<sub>2</sub> sheet



Fig. S5 Evolution of potential energy of  $TiC_2$  during AIMD simulations at 350 K.  $4 \times 4 \times 1$  supercell is used to reduce the constraint of periodic condition in the axial direction. The insets show snapshots of atomic configurations at the beginning and the end of the simulations.

### 6. Electronic Properties of the TiC<sub>2</sub> sheet



Fig. S6 Band structure of the TiC<sub>2</sub> sheet (center panel), the C<sub>2</sub> sublattice (left panel), and Ti sublattice (right panel). The high symmetric k point path is along  $\Gamma(0, 0, 0) \rightarrow Y(0, 1/2, 0) \rightarrow$ 

S (1/2, 1/2, 0)  $\rightarrow \Gamma$  (0, 0, 0)  $\rightarrow X$  (1/2, 0, 0)  $\rightarrow S$  (1/2, 1/2, 0), corresponding to the axial direction in the real space.

7. Application of the TiC<sub>2</sub> sheet as Li ion battery anode material



Fig. S7 Considered migration paths of a Li "monovacancy" on the  $TiC_2$  sheet with the high coverage of  $TiC_2Li_2$ .



Fig. S8 The energy barrier profiles of Li diffusion on  $TiC_2$  with the high coverage of  $TiC_2Li_2$ . The diffusion paths have been indicated in Figure S7.

#### Calculation Details: Estimation of the open circuit voltage (OCV)

Typically, the anode charge/discharge processes assume the following half-cell reaction that involves Li/Li<sup>+</sup>:

$$TiC_2 + xLi^+ + xe^- \not\in TiC_2Li_x$$
 \\* MERGEFORMAT (1)

The (OCV) for an intercalation reaction involving x Li<sup>+</sup> ions is computed from the energy difference of the products and the reactants.

The electronic potential during this process can be written in the form of Gibbs free energy:

$$V = -\Delta G_f / zF \qquad \land * \text{ MERGEFORMAT (2)}$$

where z and F are the number of valence electrons during the adatom process and the Faraday constant, respectively;  $\Delta G_f$  is the change in Gibbs free energy during the adatom

process which is defined as:

$$\Delta G_f = \Delta E_f + P \Delta V_f - T \Delta S_f \quad \backslash * \text{ MERGEFORMAT (3)}$$

 $P\Delta V_f$  is on the order of  $10^{-5}$  eV and the term  $T\Delta S_f$  is comparable to 26 meV at low temperature.<sup>4,5</sup> Thus, the entropy (thermal) effects and pressure terms are negligible, and will not be discussed further. $\Delta G_f$  is then approximately equal to the formation energy,  $\Delta E_f$ , involved in the adsorption process, which is defined as:

$$\Delta E_{f} = E(TiC_{2}Li_{x}) - E(TiC_{2}) - xE(Li) \land \text{* MERGEFORMAT (4)}$$

Here E (TiC<sub>2</sub>) denotes the total energy of pristine TiC<sub>2</sub> monolayer, E (Li) and E (TiC<sub>2</sub>Li<sub>x</sub>) are the total energy of bulk bcc Li and the lithiated TiC<sub>2</sub> sheet (x Li atoms adsorbed in one supercell), respectively. The OCV is related to the formation energy by:

$$OCV = \Delta G_f / x \approx \Delta E_f / x = \left[ E(TiC_2) + xE(Li) - E(TiC_2Li_x) \right] / x$$

MERGEFORMAT (5)

#### References

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